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	Application Number	10/081439
	Filing Date	February 20, 2002
	First Named Inventor	Ahn, Kie
	Group Art Unit	2818
	Examiner Name	Unknown
Sheet 1 of 1	Attorney Docket No: 01303.046US1	

US PATENT DOCUMENTS						
Examiner Initial *	USP Document Number	Publication Date	Name of Patentee or Applicant of cited Document	Class	Subclass	Filing Date If Appropriate

FOREIGN PATENT DOCUMENTS						
Examiner Initials *	Foreign Document No	Publication Date	Name of Patentee or Applicant of cited Document	Class	Subclass	T *

OTHER DOCUMENTS -- NON PATENT LITERATURE DOCUMENTS			
Examiner Initials *	Cite No	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.	T *
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not provided

EXAMINER	<i>Douglas White</i>	DATE CONSIDERED	<i>9 Mar 04</i>
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